L Number	Hits	Search Text	DB	Time stamp
11	1087	521/61,76,154.ccls.	USPAT;	2004/01/12 09:15
			US-PGPUB;	200 1/0 1/12 07:15
			EPO; JPO;	
			DERWENT	
12	4	521/61,76,154.ccls. and ((((dielectric insulating) near film) and ((curing	USPAT;	2004/01/12 09:16
		cured cure crosslink crosslinking crosslinked harden hardening hardened	US-PGPUB;	
		vulcanize vulcanizing vulcanized) same (oven furnace) same (inert	EPO; JPO;	
		n?sub.2 he! Ar! nitrogen helium argon))))	DERWENT	
14	4	(521/61,76,154.ccls. and ((((dielectric insulating) near film) and ((curing	USPAT;	2004/01/12 09:16
		cured cure crosslink crosslinking crosslinked harden hardening hardened	US-PGPUB;	200 #01/12 07.10
		vulcanize vulcanizing vulcanized) same (oven furnace) same (inert	EPO; JPO;	
ļ		n?sub.2 he! Ar! nitrogen helium argon))))) not	DERWENT	
		(428/447,116,304.4,308.4,312.2,312.6,315.7,318.4,319.1,319.3,332.450.2)	09 446-427/387	180 108 100 201 224 2
15	1	(521/((1)76.4cffice) substit(g)(distribution) insulf(ting) reconfetted and (costing	USPAT;	2004/01/12 09:18
		crossi inkingrassishinkedshirden gerdeslimgedshinded valchning hardened	US-PGPUB;	2004/01/12 09:18
i		vulcanizingulodoiningd)ulami (ed)esafum(ace)rsdure (ine)rsanfisulinelite! Ar!	EPO; JPO;	
		nProbehineliam aigoge)) helium argon))))) not ((((dielectric insulating)	DERWENT	
		near film) and ((pore porous void) near (monodiperse monodispersed	DEKWENT	
		monodispersion monodispersion))) (((dielectric insulating) near film)		
j	j	and (((particle powder) same (void pore)) same (nanometer nanometere		į į
Ì	İ	nm!)) (((dielectric insulating) near (binder film)) and ((((particle	!	
ļ		powder) same (void pore)) same (nanometer nanometere nm!)) same		
		((uniform uniformly equal equally) near (space spaced separated		i
		distribute distributed distributing separate dispersed disperse))))		
1	j	((((particle powder) same (void pore)) same (nanometer nanometere	İ	
	ĺ	nm!)) and (("3-D" 3d "three-dimensional" "3-dimensional" (three near		i
		dimesnional)) near lattice)) (((dielectric insulating) near film) and		
	i	(("3-D" 3d "three-dimensional" "3-dimensional" (three near		
		dimesnional)) near lattice) (((((particle powder) same (void pore)) same		
<u> </u>	[(nanometer nanometere nm!)) and ((curing cured cure crosslink		
		crosslinking crosslinked harden hardening hardened vulcanize		
		vulcanizing vulcanized) game (aven forman)		
		vulcanizing vulcanized) same (oven furnace) same (inert n?sub.2 he! Ar!		
		nitrogen helium argon))) and (((dielectric insulating) near film) and		
		((curing cured cure crosslink crosslinking crosslinked harden hardening		
		hardened vulcanize vulcanizing vulcanized) same (oven furnace) same		
6	2	(inert n?sub.2 he! Ar! nitrogen helium argon)))) (((((particle powder)		
0	2	\$21h6(1y66) lpfere) lsanmed (((in all all lefter in through the mention) light in its ((time may icomed))	USPAT;	2004/01/12 09:18
		(time enosstidknerossimiki)) gears attinked harden hardening hardened	US-PGPUB;	
		vulcanize vulcanizing vulcanized) same (oven furnace) same (inert	EPO; JPO;	
<u>, </u>		n?sub.2 he! Ar! nitrogen helium argon))) and (((dielectric insulating) near	DERWENT	
7	2	(Tildal) (and (Color and Louis and Color and C	USPAT;	2004/01/12 09:18
		(throterning rhimlens ibual chnizer latticen) dingty (blcdiritend) is simulation) near	US-PGPUB;	
		film acodes (more importantes subia) becala (funito directed importantis necessity)	EBO: IBO	
		(Admothspelson) on an incomparation of the control	9 0148.W 2EX887	89,198,199,201,226,24
	i	and (((particular) wiscular sugget (san on protein cancer truen ourset burst ourset burset burst ourset burst	. , ======,,,	,,,,,,
	1	orns) ink (negietosstiicakestitutiden) headchingdrafidente danut Kaariaeticle	1	
1		polyder) isagnat (verbitzpd) espresario (cranformeter) isanom (chene nest) in Sahrel Art		
		((intrigembehiniorargoed)))))))((uavatembear sodub ka)azardes é oxidte dilica		
		(ligationalei chistriliotori) dicituliori de jeganza pahispleri eni di (((édiscli)) tric	i	
		(neighbaring) peardem) and (wid mornic shour enaposite tempor inking		
		oros)) interdefiliar Den But interior of impositional Viller discount into redemize d		
	1 +	sames(riveralli) mezae lestice) (in ((the suchrit his sulating) organ fichin) rand		
	1.	((god)))) d) ((h)(esatembesicaellbis) diracpairticall) ((h)reidnesitica		ļ
	1	((goesnional))cileandataidedidx(((())arainte potentraradi(((((dieldeprice)) same		
		(nandations) reproduction of the control of the con		
		crosslinkinghanoksiihkedehingehahdededinglhandenedikairiningevulcanized)		
	[]	sariezańczieg kurkzonizedinza(necho resultuzalez). Azinci (negenitezinia ingloh))	1	
İ	ì	hi)rogen helium argon))) and (((dielectric insulating) near film) and	1	
	1	((curing cured cure crosslink crosslinking crosslinked harden hardening		
		recording cured cure crossinik crossiniking crossiniked harden hardening nardened vulcanize vulcanizing vulcanized) same (oven furnace) same	İ	
		(inert n?sub.2 he! Ar! nitrogen helium argon)))) (((((particle powder)	ļ	
		rame (void pore)) same (nanomator range))) (((((particle powder)		
		same (void pore)) same (nanometer nanometere nm)) and ((curing cured		
		cure crosslink crosslinking crosslinked harden hardening hardened vulcanize vulcanizing vulcanized) same (oven furnace) same (inert	1	

vulcanize vulcanizing vulcanized) same (oven furnace) same (inert n?sub.2 he! Ar! nitrogen helium argon))) and (((dielectric insulating) near Search History 1/12/04 9:20:n)3and((culrace) dured cure crosslink crosslinking crosslinked harden C:\APPS\EAST\Workspaces\amble 0.00 and (culrace) same (oven f ce e e ? b 2 he A ge he g

L Number			DB	Time stamp
1	2	2 ((dielectric insulating) near film) and ((pore porous void) near (monodiperse monodispersed monodispersion monodispersion))	USPAT; US-PGPUB;	2004/01/12 07:25
		, and a second monotonical second	EPO; JPO; DERWENT	
2	18		USPAT;	2004/01/12 07:25
	İ	(dielectric near constant)) and (nanoparticle ((particle nowder) same	US-PGPUB;	
3		(nanometer nanometere nm!)))) and ((first second) near phase)	EPO; JPO;	
	63	((((diolognia 'and d'an) and d'an)	DERWENT	
	03	- Comment in the state of the s	USPAT;	2004/01/12 07:25
		(dielectric near constant)) and (nanoparticle ((particle powder) same (nanometer nanometere nm!)))) and lattice	US-PGPUB;	
		("anomotor manomotore min;)))) and native	EPO; JPO;	
4	70	(((((,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,	DERWENT USPAT;	2004/01/12 07:26
i		(dielectric near constant)) and (nanoparticle ((particle powder) same	US-PGPUB;	2004/01/12 07:26
		(nanometer nanometere nm!)))) and (silsesquioxane	EPO; JPO;	
		polyorganosilsesquioxane organosilsesquioxane	DERWENT	
		organopolysilsesquioxane polysilsesquioxane methylsilsesquioxane		
		hydrogensilsesquioxane phenylsilsesquioxane		
		polyhydrogensilsesquioxane hydrogenpolysilsesquioxane polymethylsilsesquioxane methylpolysilsesquioxane		
		polyphenylsilsesquioxane phenylpolysilsesquioxane)		
5	2	((suspension same (water near soluble) same (oxide silica ((germanium	USPAT;	2004/01/12 07 04
		silicon) adj dioxide)) same particle) same (surface near (treated modified	US-PGPUB;	2004/01/12 07:26
		treating modifying treat modify coat coated coating))) and ((dielectric	EPO; JPO;	
		insulating) same binder)	DERWENT	
5	131	1 (Control of the control PAT;	2004/01/12 07:26	
		pore)) same (nanometer nanometere nm!))	US-PGPUB;	
			EPO; JPO;	i l
7	15	((dielectric insulating) pear (hinder film)) and ((((, , , , , , , , , , , , , , , , ,	DERWENT	
	1	((dielectric insulating) near (binder film)) and ((((particle powder) same (void pore)) same (nanometer nanometere nm!)) same ((uniform	USPAT;	2004/01/12 07:27
		uniformly equal equally) near (space spaced separated distribute	US-PGPUB;	
		distributed distributing separate dispersed disperse)))	EPO; JPO; DERWENT	
3	131	((dielectric insulating) near film) and (((particle powder) same (void pore)) same (nanometer nanometere nm!))	USPAT;	2004/01/12 07:27
			US-PGPUB;	2004/01/12 07:27
			EPO; JPO;	
	17	(((nowish =	DERWENT	
	17	(((particle powder) same (void pore)) same (nanometer nanometere nm!)) and (("3-D" 3d "three-dimensional" "3-dimensional" (three near dimesnional)) near lattice)	USPAT;	2004/01/12 07:27
			US-PGPUB;	
		amomonal) hear factor)	EPO; JPO;	
0	17	((((particle powder) same (void pore)) same (nanometer nanometere nm!)) and (("3-D" 3d "three-dimensional" "3-dimensional" (three near	DERWENT	0004/01/10 07 00
1	i		USPAT; US-PGPUB;	2004/01/12 07:28
1		dimesnional)) near lattice))	EPO; JPO;	
	_	// 1	DERWENT	
1	9	((dielectric insulating) near film) and (("3-D" 3d "three-dimensional"	USPAT;	2004/01/12 07:28
		"3-dimensional" (three near dimesnional)) near lattice)	US-PGPUB;	
			EPO; JPO;	
2	16	428/447 116 304 4 308 4 312 2 312 6 315 7 318 4 310 1 310 3 332 432	DERWENT	
		428/447,116,304.4,308.4,312.2,312.6,315.7,318.4,319.1,319.3,332,450,20 and (("3-D" 3d "three-dimensional" "3-dimensional" (three near	9, 00 869,4227,/387,1	8 901048011997207,28 6 243
	i	dimesnional)) near lattice)	US-PGPUB;	
		,	EPO; JPO; DERWENT	
3	21	((((particle powder) same (void pore)) same (nanometer nanometere	USPAT;	2004/01/12 07:29
		hardening hardened vulcanize vulcanizing vulcanized) same (oven	US-PGPUB;	2007/01/14/07.29
			EPO; JPO;	
		rurnace) same (mert n'sub.2 he! Ar! nitrogen helium argon))) and	DERWENT	
		(((dielectric insulating) near film) and ((curing cured cure crosslink		
		crosslinking crosslinked harden hardening hardened vulcanize vulcanizing vulcanized) same (oven furnace) same (inert n?sub.2 he! Ar!		
		nitrogen helium argon)))		

14	27	428/447 116 304 4 308 4 312 2 212 (215 7 218 4 210 1 210 2 222 452 2	h	
		428/447,116,304.4,308.4,312.2,312.6,315.7,318.4,319.1,319.3,332,450,20	0 9,4460,A2 7,/387,	[8 2 010980119922017;2126]243,;
		and ((((dielectric insulating) near film) and ((curing cured cure crosslink	US-PGPUB;	
		crosslinking crosslinked harden hardening hardened vulcanize	EPO; JPO;]
15	2	vulcanizing vulcanized) same (oven furnace) same (inert n?sub.2 he! Ar!	DERWENT	[
1.0	2	hitwagenmaliusolahgongame (oxide silica ((germanium silicon) adj	USPAT;	2004/01/12 07:31
		dioxide)) same particle) and ((((dielectric insulating) near film) and	US-PGPUB;	
		((curing cured cure crosslink crosslinking crosslinked harden hardening	EPO; JPO;	
	İ	hardened vulcanize vulcanizing vulcanized) same (oven furnace) same	DERWENT	
10	104	(inert n?sub.2 he! Ar! nitrogen helium argon))))		
16	104	(((water near soluble) near particle) ((oxide silica ((germanium silicon)	USPAT;	2004/01/12 07:33
		adj dioxide)) same water)) and ((((dielectric insulating) near film) and	US-PGPUB;	
		((curing cured cure crosslink crosslinking crosslinked harden hardening	EPO; JPO;	
	1	hardened vulcanize vulcanizing vulcanized) same (oven furnace) same	DERWENT	
		(inert n?sub.2 he! Ar! nitrogen helium argon))))		
17	46	((((dielectric insulating) near film) and ((pore porous void) near	USPAT;	2004/01/12 07:33
		(monodiperse monodispersed monodispersion monodispersion)))	US-PGPUB;	2004/01/12 07.33
		((((((dielectric insulating) near film) and (pore porous void)) and	EPO; JPO;	
		(dielectric near constant)) and (nanoparticle ((particle powder) same	DERWENT	
		(nanometer nanometere nm!)))) and ((first second) near phase))	DERWENT	
	i	((((((dielectric insulating) near film) and (pore porous void)) and		
		(dielectric near constant)) and (nanoparticle ((particle powder) same		
		(nanometer nanometere nm!)))) and lattice) (((((dielectric insulating)		
		near film) and (pore porous void)) and (dielectric near constant)) and	İ	
	1	(nanoparticle ((particle powder) same (nanometer nanometere nm!)))) and		
	İ	(silsesquioxane polyorganosilsesquioxane organosilsesquioxane		
		organopolysilsesquioxane polysilsesquioxane methylsilsesquioxane		j
		hydrogensilsesquioxane phenylsilsesquioxane		
		polyhydrogensilsesquioxane hydrogenpolysilsesquioxane		
		polymethylsilsesquioxane methylpolysilsesquioxane polymethylsilsesquioxane methylpolysilsesquioxane		
	1 1	polymenyleilesequiovane nleunylpolyshsesquioxane		i
		polyphenylsilsesquioxane phenylpolysilsesquioxane)) (((suspension		
		same (water near soluble) same (oxide silica ((germanium silicon) adj		1
		dioxide)) same particle) same (surface near (treated modified treating		
		modifying treat modify coat coated coating))) and ((dielectric insulating)		
		same binder)) (((dielectric insulating) near film) and (((particle powder)		ļ
	1 1	same (void pore)) same (nanometer nanometere nm!))) (((dielectric		
		insulating) near (binder film)) and ((((particle powder) same (void pore))		
		same (nanometer nanometere nm!)) same ((uniform uniformly equal		
		equally) near (space spaced separated distribute distributed distributing		
	1	separate dispersed disperse)))) (((dielectric insulating) near film) and		
	[]	(((particle powder) same (void pore)) same (nanometer nanometere nm!))		
) ((((particle powder) same (void pore)) same (nanometer nanometere		
		nm!)) and (("3-D" 3d "three-dimensional" "3-dimensional" (three near	j	
	[dimesnional)) near lattice)) (((((particle powder) same (void pore)) same		
	<u> </u>	(nanometer nanometere nm!)) and (("3-D" 3d "three-dimensional"		
		"3-dimensional" (three near dimesnional)) near lattice))) (((dielectric		

"3-dimensional" (three near dimesnional)) near lattice))) (((dielectric insulating) near film) and (("3-D" 3d "three-dimensional" "3-dimensional" (three near dimesnional)) near lattice)) and (("3-D" 3d "three-dimensional" "3-dimensional" (three near dimesnional)) near lattice)) (((((particle powder) same (void pore)) same (nanometer nanometere nm!)) and ((curing cured cure crosslink crosslinking crosslinked harden hardening hardened vulcanize vulcanizing vulcanized) same (oven furnace) same (inert n?sub.2 he! Ar! nitrogen helium argon))) and (((dielectric insulating) near film) and ((curing cured cure crosslink crosslinking crosslinked harden hardening hardened vulcanize vulcanizing vulcanized) same (oven furnace) same (inert n?sub.2 he! Ar! nitrogen helium argon)))) (428/447,116,304.4,308.4,312.2,312.6,315.7,318.4,319.1,319.3,332,450,209,446;427/387,189,198,199,201,226,243 and ((((dielectric insulating) near film) and ((curing cured cure crosslink crosslinking crosslinked harden hardening hardened vulcanize vulcanizing vulcanized) same (oven furnace) same (inert n?sub.2 he! Ar! nitrogen helium argon))))) (((water near soluble) same (oxide silica ((germanium silicon) adj dioxide)) same particle) and ((((dielectric insulating) near film) and ((curing cured cure crosslink crosslinking crosslinked harden hardening hardened vulcanize vulcanizing vulcanized) same (oven furnace) same (inert n?sub.2 he! Ar! nitrogen helium